

APPLICATION FORM



Centre for Research in Rural and Industrial Development (CRRID) Sector 19-A, Madhya Marg, Chandigarh – 160 019 (INDIA)

		r
Ten Days Research Methodology Course in Social Sciences		Paste
(June 10-19, 2019)	Attested
Sponsored by		Photograph
Indian Council of Social Science Res	earch, New Delhi	
(All Fields Mandator	y)	
Name (in Block Letters):		
Gender (M/F)Social Category (SC/ST	/OBC/General)	
Date of Birth: Educational Qualificat	ion:	
Programme in which enrolled (M.Phil/Ph.D./PDF):		
*Date of enrolment/registration:		
*Enrolment/registration No		
Name of the institution:		
*Topic of the Thesis/Research:		
(*Attach a brief of Introduction, Objectives, Hypotheses and	Research Methodology)	
Have you attended similar course earlier: Yes ()	No ()	
*If yes, provide details:		
Mailing Address (Official):		
(Residential):		
Mobile No:		
E-mail Address:		
Accommodation Required at CRRID (please tick mark): Yes () No ()	
*Present status of Research:	(Attach a separate sheet)	
	Signature of the C	andidate

Address: _____

*Supply copy of the document (mandatory)

Forwarding letter from the Supervisor/ Principal/ Head of the Department

(Forwarded to):

The Course Director, ICSSR Sponsored Research Methodology Course, Centre for Research in Rural & Industrial Development, Sector 19-A, Madhya Marg, Chandigarh-160 019 I recommend Mr./Ms. ______currently enrolled for M.Phil/Ph.D./PDF programme (tick mark applicable) in the subject ______at (Institution) ______

for the ICSSR sponsored Research Methodology Course in Social Sciences (June 10-19, 2019) at

CRRID, Chandigarh. He/She will be relieved to participate in the above course, if selected.

Details furnished by him/her are verified and found correct.

Dated:

Signature of the Supervisor

Signature of the Principal / Head of the Department

Dated:

Official Seal

Important Note:

The candidates shall also submit in online mode and in PDF format, along with their above application form, the recommendations of the supervisor in regard to their competence and motivation.